

# LiWa Inhib Clean

## **Description:**

LiWa Inhib Clean is a liquid to remove the inhibition layer from polymerized modellations of the light-curing resin LiWa. LiWa Inhib Clean is based on alcohol.

LiWa Inhib Clean is part of a wide range of materials: resins in different consistencies, preformed resin patterns, useful complementary materials for different areas of use as well as functional sets.

## **Properties:**

- Easy handling
- Quick removal of the inhibition layer

## **Advantages:**

- Time-saving

## **Indication:**

- Liquid to remove the inhibition layer from polymerized LiWa modellations. Can also be used with the light-curing tray material Plaque Photo.

**Storage conditions:** dry and protected from light at 0 - 22 °C

**Shelf life:** 3 years

## **Presentation:**

WP5084: LiWa Inhib Clean, liquid, 250 ml bottle

